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Cu<sub>2</sub>Si  
ELETTRA

10<sup>16</sup> / cm<sup>2</sup>

100

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Cu<sub>2</sub>Si  
100

Sugino, Tai-Chang Chiang, Kenya Shimada, Koji Miyamoto, Taichi Okuda, Kehui Wu, Lan Chen, Yugui Yao, and Iwao Matsuda

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TEL: 04-7136-3290 04-7136-3296  
E-mail sugino@issp.u-tokyo.ac.jp

LASOR

TEL: 04-7136-3402  
FAX: 04-7136-3283  
Email: imatsuda@issp.u-tokyo.ac.jp

0791-58-0802 ext. 3619  
0791-58-1886

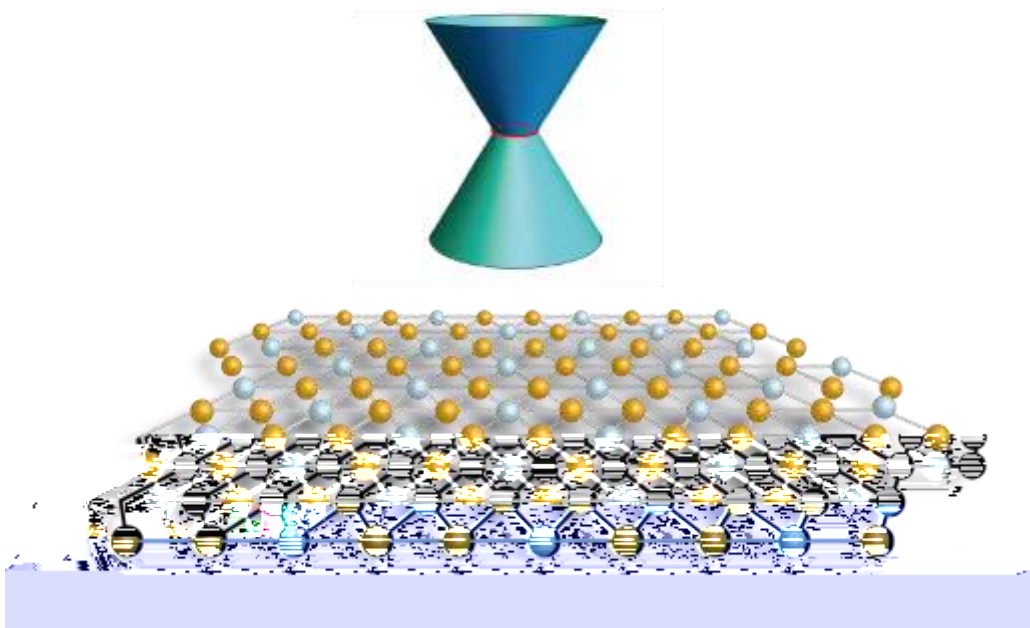
FENG BAOJIE

TEL:082-424-6999  
Email:kshimada@hiroshima-u.ac.jp

TEL: 04-7136-3207  
E-mail: press@issp.u-tokyo.ac.jp

TEL:082-424-6762  
E-mail: koho@office.hiroshima-u.ac.jp

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$\text{Cu}_2\text{Si}$

Cu

Si

